

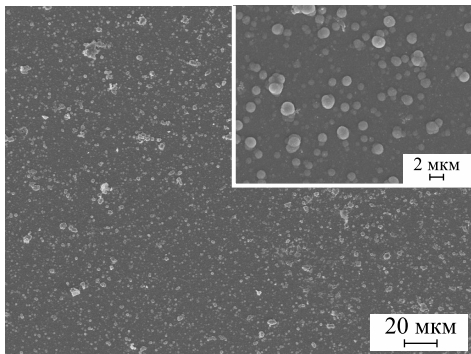
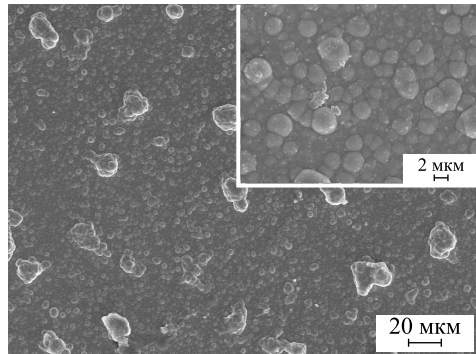
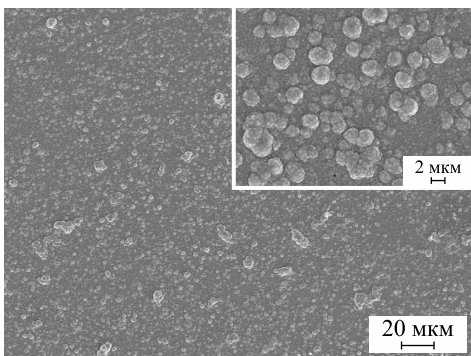
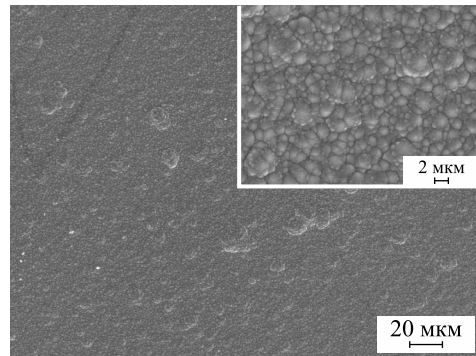
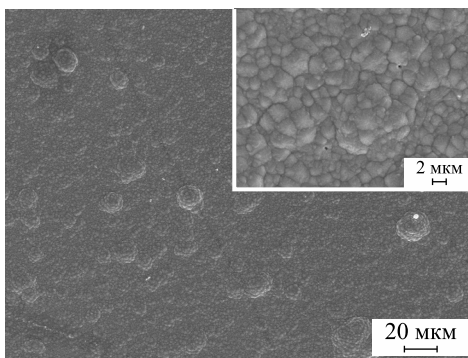
a/a*б/б**в/с**г/д**д/е*

Рис. 2. СЭМ-фотографии поверхности покрытий Ni – Sn толщиной 1 мкм (*а, в*), 5 мкм (*б, г*) и 10 мкм (*д*), осаждаемых из ЭГ электролитов № 4 (*а, б*) и № 5 (*в – д*) при плотности тока 0,5 А/дм²

Fig. 2. SEM images of the surface of Ni – Sn coatings with the thickness of 1 μm (*a, c*), 5 μm (*b, d*) and 10 μm (*e*) deposited from ethylene glycol electrolytes No. 4 (*a, b*) and No. 5 (*c – e*) at the current density 0.5 A/dm²